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Viewing: MEMS 211 : MICRO-FABRICATION PROCESSING

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Is this a fast track change? No

Course ID 110657

Subject MEMS - Micro-Electromechanical Systems Course Number 211

Title MICRO-FABRICATION PROCESSING

Division Engineering Technologies

Effective Term Spring 2023

Method of Delivery In Person

Typically Offered Offered Fall Term Only

CIP Code 15.0616 - Semiconductor Manufacturing Technology/Technician.

SOC Code



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The Ohio Manufacturing Workforce Partnership (OMWP) is a collaboration of The Ohio Manufacturers' Association (OMA) and Ohio TechNet (OTN). Established to address Ohio's manufacturing workforce shortage, the OMWP works directly with a statewide network of manufacturing industry sector partnerships and is focused on meeting local employment and skill needs.

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Standard Occupational Classification (SOC)	Standard Occupational Classification Title
17-3023	Electrical and Electronics Engineering Technicians
51-9141	Semiconductor Processors

Course Level

Technical

Is this an international course?

Grading Basis

Graded

Grading Procedures

Graded Element	% of overall course grade
Laboratory	40%
Homework/Quizzes/Exams	40%
Final Exam	20%

Upload Sample Syllabus

Course Hours

Minimum Credit Hours

3

Maximum Credit Hours

3

Is this course repeatable for credit?

No

Course Components

Lecture Laboratory

Component Hours, ILUs, and Seats

Lecture: Contact Hours

ILUs

Seats

Laboratory: Contact Hours

ILUs

Seats

Total Course Contact Hours

Special Fees

Special Fee Yes

Type of Fee Supplies/Materials **Amount** 75

Catalog Information

Crosslisted

Course Description

The course focuses strongly on the theory, terminology, application and hands-on industry practices in silicon wafer fabrication and Printed Wiring Board (PWB) fabrication with continued practice in working in a cleanroom. Topics include photolithography, chemical etching, and DC magnetron sputtering. Lab required

Prerequisite MEMS 132 & ELCT 111

Corequisite CHMY 171

Concurrent

Course Placement Policy

Topical Outline: Please enter each of the Topical Outline items as a bullet.

• Silicon wafer processing – handling, cleaning, and safe chemical processing including HF acid

- Silicon material science and semiconductor fabrication processes
- Photolithography Theory, terminology, application, and optimization for both silicon wafers and printed wiring board (PWB)
- Wet chemical etching of PCB and PWB Fabrication and the relation to silicon wafer processing
- Inspection and metrology of photolithographic processed materials including spectroscopy, profilometry, and general visual inspection
- Chemical and material processing including wet chemical etching and plasma etching
- Thin film deposition techniques including sputtering and electron beam evaporation

College Ready Requirement

English

Reading

Math

Course Outcomes and Assessment

Outcome Number:

1

Outcome

Explain terminology, processes, materials, and standards used in the fabrication of integrated circuits, microelectromechanical system sensors, or bare printed wiring boards.

Domain Cognitive

Assessment Tools Examination

Assessment Method

Rubric

Benchmark %

70% of students will earn 70% or higher on selected instrument

Benchmark %

Other Benchmark

Corresponding GE Outcomes

C1 English C3 Science In1 Critical Thinking

Outcome Number:

2

Outcome

Process a silicon wafer with photolithographic artwork.

Domain

Psychomotor

Assessment Tools

Laboratory exercise

Assessment Method

Rubric

Benchmark %

70% of students will earn 70% or higher on selected instrument

Benchmark %

Other Benchmark

Corresponding GE Outcomes

C1 English C2 Mathematics C3 Science In1 Critical Thinking

Outcome Number:

3

Outcome

Fabricate a printed wiring board using photolithography and etching techniques that can be soldered as a functional PCB.

Domain

Psychomotor

Assessment Tools

Laboratory exercise

Assessment Method

Rubric

Benchmark %

70% of students will earn 70% or higher on selected instrument

Benchmark %

Other Benchmark

Corresponding GE Outcomes

C1 English C2 Mathematics C3 Science In1 Critical Thinking

General Education/Other

Type of Course

Technical

Core Course Outcomes

Core Course Outcomes

C3 Natural Science: Apply scientific concepts and methods of inquiry.

Infused Course Outcomes

Infused Course Outcomes

In1 Critical Thinking: Employ critical thinking skills in addressing issues and problems.In2 Communication: Demonstrate competence in verbal and nonverbal communicationIn5 Health: Identify behaviors that promote health of the individual

Experiential Learning

Does this course have an experiential component? No Suggested Instructional Method(s) and Technique(s) Lectures In-lab demonstrations Laboratory exercises performed individually

State Articulation and Transfer

Transfer Module:

Transfer Assurance Guide and Career Technical Credit Transfer

Accreditation/Licensure/Certification

Does this course prepare or substantially prepare a student for a license or certification? Note: This section applies to an individual course that may have a certification and/or licensure. (e.g. CPR course)

No

Additional Resources

Additional Resources

Textbooks/OER

Туре

Textbook and OER

Required or Optional Required

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Copyright Year 2010

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URL https://link.springer.com/book/10.1007/978-0-387-09511-0

Additional Notes On LCCC Campus, book can be downloaded as a .pdf for free

Other Materials

Required Materials

Optional Materials

Additional Notes

Notes

Rationale

Rationale and Dean's Statement of Support

Attach Additional Support Documentation

Reviewer Comments

Key: 1697

Select any proposals you would like to bundle together for approval. Only proposals you have saved are available to bundle.

Bundle Title:

Course: Proposal A Program: Proposal B